Department of Defense Fiscal Year (FY) 2024 Budget Estimates

March 2023



Office of the Secretary Of Defense

Defense-Wide Justification Book Volume 3 of 5

Creating Helpful Incentives To Produce Semi-Conductors (CHIPS) for America

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Office of the Secretary Of Defense • Budget Estimates FY 2024 • RDT&E Program

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Program Element Table of Contents (by Budget Activity then Line Item Number)

Appropriation 0403D: Creating Helpful Incentives To Produce Semi-Conductors (CHIPS) for America

Line #	Budget Activity	Program Element Number	Program Element Title Pa	ge
999	02	0602669D8Z	Microelectronics Commons Volume 3 ·	- 1
Appropriat	ion 0403D: Creatin	ng Helpful Incentives To Produce	Semi-Conductors (CHIPS) for America	
Line #	Budget Activity	Program Element Number	Program Element Title Pa	ge
999	03	0603669D8Z	Microelectronics Commons Volume 3 ·	- 7
Appropriat		ng Helpful Incentives To Produce Program Element Number	Semi-Conductors (CHIPS) for America Program Element Title Pa	ge
999	04	0604669D8Z	Microelectronics Commons Volume 3 -	19

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Exhibit R-2, RDT&E Budget Item Justification: PB 2024 Office of the Secretary Of Defense								Date: March 2023				
Appropriation/Budget Activity 0403D: Creating Helpful Incentive America I BA 2: Applied Research		ce Semi-Co	nductors (C		-	1 Program Element (Number/Name) 2 0602669D8Z / Microelectronics Commons						
COST (\$ in Millions)	Prior Years	FY 2022	FY 2023	FY 2024 Base	FY 2024 OCO	FY 2024 Total	FY 2025	FY 2026	FY 2027	FY 2028	Cost To Complete	Total Cost
Total Program Element	-	0.000	65.062	65.062	-	65.062	72.188	79.709	72.979	0.000	Continuing	Continuing
825: Microelectronics Research Maturation-Development	-	0.000	63.395	63.395	-	63.395	60.521	57.487	60.201	0.000	Continuing	Continuing
827: Workforce Development	-	0.000	1.667	1.667	-	1.667	11.667	22.222	12.778	0.000	Continuing	Continuing

<u>Note</u>

Funding begins in FY 2023 as provided in the Creating Helpful Incentives to Produce Semiconductors (CHIPS) Act of 2022 appropriation, not in the FY 2023 annual Defense appropriation.

A. Mission Description and Budget Item Justification

This program supports the Department's initiatives to Build Sustainable and Long-Term Advantage, Defend the Homeland, and Deter Aggression.

The Office of the Under Secretary of Defense for Research and Engineering (OUSD(R&E)) is standing up the Microelectronics (ME) Commons activity pursuant to the Fiscal Year (FY) 2021 National Defense Authorization Act (NDAA) (Pub. L. 116-283), including the CHIPS (Creating Helpful Incentives to Produce Semiconductors) for America Act, and funded through the CHIPS for America Defense Fund established by the CHIPS Act of 2022. The FY 2021 NDAA legislation significantly emphasizes solutions that promote the domestic on-shoring of capabilities to address economic and technology security concerns. Under FY 2021 NDAA Sec. 9903(b), DoD is directed to establish a National Network for Microelectronics Research and Development (NNMRD) to enable the laboratory-to-fabrication transition of microelectronics innovations in the United States and to expand the global leadership in microelectronics of the United States. Specifically, DoD is addressing a component of the NNMRD, the ME Commons, through a public-private partnership consisting of regional innovation hubs distributed across the U.S. to foster a pipeline of innovative ideas and talent residing in university labs and small business R&D teams.

Background

U.S. technological dominance in ME materials, processes, devices, and architectural designs can only be sustained through the development of a robust domestic innovation ecosystem that fosters the rapid development and transition of novel concepts into commercially viable manufacturing processes. The U.S. innovation ecosystem has long been the driver of our nation's technology leadership throughout the world. U.S. R&D kick-started the enormous semiconductor industry and continues to lead the world in developing the next generation of disruptive technologies including: new materials, devices, circuits, architectures, and design tools.

In recent years, the efficient domestic adoption of U.S. chip innovation has been threatened as emerging hardware technologies have become increasingly reliant on offshore sources for State of the Art (SOTA) manufacturing, prototyping, and investment. There are several significant hurdles that hardware startups face, including limited or expensive access to necessary facilities and design infrastructure, high costs of design intellectual property, limited expertise with hardware engineering, and high costs of prototyping. As a result, the number of U.S. hardware startups has dropped significantly and foreign investment in U.S.-based technology startups has enabled offshore fabrication and maturation of emerging technologies.

Exhibit R-2, RDT&E Budget Item Justification: PB 2024	4 Office of the Secretar	ry Of Defense		Date:	March 2023
Appropriation/Budget Activity			ement (Number/Name)		
0403D: Creating Helpful Incentives To Produce Semi-Con America I BA 2: Applied Research	ductors (CHIPS) for	PE 0602669D8Z	I Microelectronics Com	imons	
To address these needs, OUSD(R&E) is standing up the	MF Commons as a pu	blic private partn	ership consisting of rec	nional innovation hubs of	distributed across the U.S.
to foster a pipeline of innovative ideas and talent residing specialized lab equipment, technical expertise, and conne facilities will help mature promising technologies and dem	in university labs and ections to existing or up	small business R ograded low-volu	R&D teams. The partne ime prototyping facilities	rship will provide resou s. These low-volume fa	rces for and access to brication and packaging
and commercial sectors.					
The ME Commons will focus on critical, on-shore prototypare:	ping to transition innov	ation from univer	sities, start-ups, and sm	nall companies to manu	facturing. Key features
Creates and connects "Lab-to-Fab" testing/prototyping h	ubs to form a network	focused on matu	urina emergina microele	ectronics technologies	
 Provides broad access to these prototyping hubs, poten 					emiconductor companies
or FFRDCs.	,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,		Ū		
Facilitates ME education and training of students at loca	I colleges and universi	ties, and provide	e a potential pipeline to l	bolster local semicondu	ctor economies and
		ties, and provide	e a potential pipeline to l	bolster local semicondu	ictor economies and
• Facilitates ME education and training of students at loca contribute more broadly to the growth of a domestic semi-	conductor workforce.				
• Facilitates ME education and training of students at local contribute more broadly to the growth of a domestic semice. This program element focuses on the applied research at	conductor workforce. ctivities of the ME Com				
• Facilitates ME education and training of students at loca contribute more broadly to the growth of a domestic semi-	conductor workforce. ctivities of the ME Com				
• Facilitates ME education and training of students at local contribute more broadly to the growth of a domestic semice. This program element focuses on the applied research as preliminary microelectronics prototyping planning, and extended of the second	conductor workforce. ctivities of the ME Com				
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 Facilitates ME education and training of students at local contribute more broadly to the growth of a domestic semice. This program element focuses on the applied research as preliminary microelectronics prototyping planning, and ex B. Program Change Summary (\$ in Millions) Previous President's Budget Current President's Budget Total Adjustments Congressional General Reductions Congressional Directed Reductions Congressional Adds Congressional Directed Transfers 	conductor workforce. ctivities of the ME Com perimental tools. <u>FY 2022</u> 0.000 0.000	mons, including <u>FY 2023</u> 0.000 65.062	staffing at ME Common <u>FY 2024 Base</u> 0.000 65.062	is hub facilities, early te	chnology identification, <u>FY 2024 Total</u> 0.000 65.062
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Change Summary Explanation

This PE is funded by the CHIPS for America Defense Fund special appropriation established by the CHIPS Act of 2022, not the annual Defense appropriation. The CHIPS Act appropriates funds for this effort from FY 2023 through 2027.

Exhibit R-2A, RDT&E Project Justification: PB 2024 Office of the Secretary Of Defense							Date: March 2023					
Appropriation/Budget Activity 0403D / 2					PE 0602669D8Z / Microelectronics Commo				Project (Number/Name) 825 <i>I Microelectronics Research Maturation-</i> <i>Development</i>			
COST (\$ in Millions)	Prior Years	FY 2022	FY 2023	FY 2024 Base	FY 2024 OCO	FY 2024 Total	FY 2025	FY 2026	FY 2027	FY 2028	Cost To Complete	Total Cost
825: Microelectronics Research Maturation-Development	-	0.000	63.395	63.395	-	63.395	60.521	57.487	60.201	0.000	Continuing	Continuing

A. Mission Description and Budget Item Justification

This project focuses on the applied research activities of the ME Commons including the early research and development of new ME materials, processes, devices, and architectural designs. It seeks to answer how new models, science, and technology can be leveraged to create a different manufacturing paradigm based on proven process tools in agile ME fabrication facilities (fabs). It also supports the establishment of the ME Commons Hubs, which will be new strategic partnerships with existing academic facilities and research labs. The Hubs will be augmented to enhance intrinsic specializations in emerging areas of ME. This project also supports the establishment of strategic relationships with Core facilities, which are existing state-of-the-art ME productions facilities (foundries or fabs). The Cores will be connected to the regional Hubs and open to all ME Commons users.

FY 2022	FY 2023	FY 2024
0.000	63.395	63.395
s 0.000	63.395	63.395
	0.000	0.000 63.395

Exhibit R-2A, RDT&E Project Justification: PB 2024 0	Office of the Secretary Of Defense	Date: March 2023			
Appropriation/Budget Activity 0403D / 2	R-1 Program Element (Number/Name) PE 0602669D8Z / Microelectronics Commo ns	Project (Number/Name) 825 / Microelectronics Research Maturation Development			
	113	Development			
D. Acquisition Strategy					
N/A					

Exhibit R-2A, RDT&E Project Justification: PB 2024 Office of the Secretary Of Defense									Date: Marc	ch 2023		
Appropriation/Budget Activity R-1 Program Element (Number PE 0602669D8Z / Microelectrol ns 0403D / 2 PE 0602669D8Z / Microelectrol ns					•	,	Project (N 827 / Work		,			
COST (\$ in Millions)	Prior Years	FY 2022	FY 2023	FY 2024 Base	FY 2024 OCO	FY 2024 Total	FY 2025	FY 2026	FY 2027	FY 2028	Cost To Complete	Total Cost
827: Workforce Development	-	0.000	1.667	1.667	-	1.667	11.667	22.222	12.778	0.000	Continuing	Continuing

A. Mission Description and Budget Item Justification

This project focuses on workforce development activities that are inherent to the operation of the ME Commons, particularly in the applied research phase of new technologies under investigation. It will facilitate ME education and training of students at local colleges and universities that are part of the Commons network, and provide a pipeline to bolster local semiconductor economies and contribute more broadly to the growth of a domestic semiconductor workforce.

B. Accomplishments/Planned Programs (\$ in Millions)	FY 2022	FY 2023	FY 2024
Title: Workforce Development	0.000	1.667	1.667
Description: This effort will directly support early workforce development activities through the ME Commons network. Activities include establishment of PhD internships and post-doc training at Hub facilities and internships at Core facilities. Additionally, it will develop training for the existing ME Commons workforce with potential for impact beyond the entities participating directly in the ME Commons Core and Hub entities.			
 FY 2023 Plans: Develop and establish internships and post-doc training programs for Hub facilities Develop and establish internships for Core facilities Develop training for existing non-student ME Commons workforce 			
 FY 2024 Plans: Continue and expand internships and post-doc training programs for Hub facilities Continue and expand internships for Core facilities Continue and expand training for existing non-student ME Commons workforce 			
FY 2023 to FY 2024 Increase/Decrease Statement: N/A			
Accomplishments/Planned Programs Subtotals	0.000	1.667	1.667
<u>C. Other Program Funding Summary (\$ in Millions)</u> N/A <u>Remarks</u>			

xhibit R-2A, RDT&E Project Justification: PB 2024 Office	ce of the Secretary Of Defense	Date: March 2023
ppropriation/Budget Activity 403D / 2	R-1 Program Element (Number/Name) PE 0602669D8Z / Microelectronics Commo ns	Project (Number/Name) 827 / Workforce Development
Acquisition Strategy		
/A		
0602669D8Z: Microelectronics Commons	UNCLASSIFIED	

Exhibit R-2, RDT&E Budget Iten	ary Of Defer	nse			Date: March 2023							
Appropriation/Budget Activity 0403D: Creating Helpful Incentives To Produce Semi-Conductors (CHIPS) for America I BA 3: Advanced Technology Development (ATD)				HIPS) for	R-1 Progra PE 060366		•	S				
COST (\$ in Millions)	Prior Years	FY 2022	FY 2023	FY 2024 Base	FY 2024 OCO	FY 2024 Total	FY 2025	FY 2026	FY 2027	FY 2028	Cost To Complete	Total Cost
Total Program Element	-	0.000	269.256	269.256	-	269.256	265.108	260.731	264.648	0.000	Continuing	Continuing
829: Microelectronics Research Maturation – Prototyping	-	0.000	267.923	267.923	-	267.923	255.775	242.953	254.426	0.000	Continuing	Continuing
830: Workforce Development – Prototyping	-	0.000	1.333	1.333	-	1.333	9.333	17.778	10.222	0.000	Continuing	Continuing

Note

Funding begins in FY 2023 as provided in the Creating Helpful Incentives to Produce Semiconductors (CHIPS) Act of 2022 appropriation, not in the FY 2023 annual Defense appropriation.

A. Mission Description and Budget Item Justification

This program supports the Department's initiatives to Build Sustainable and Long-Term Advantage, Defend the Homeland, and Deter Aggression.

The Office of the Under Secretary of Defense for Research and Engineering (OUSD(R&E)) is standing up the Microelectronics (ME) Commons activity pursuant to the Fiscal Year (FY) 2021 National Defense Authorization Act (NDAA) (Pub. L. 116-283), including the CHIPS (Creating Helpful Incentives to Produce Semiconductors) for America Act, and funded through the CHIPS for America Defense Fund established by the CHIPS Act of 2022. The FY 2021 NDAA legislation significantly emphasizes solutions that promote the domestic on-shoring of capabilities to address economic and technology security concerns. Under FY 2021 NDAA Sec. 9903(b), DoD is directed to establish a National Network for Microelectronics Research and Development (NNMRD) to enable the laboratory-to-fabrication transition of microelectronics innovations in the United States and to expand the global leadership in microelectronics of the United States. Specifically, DoD is addressing a component of the NNMRD, the ME Commons, through a public-private partnership consisting of regional innovation hubs distributed across the U.S. to foster a pipeline of innovative ideas and talent residing in university labs and small business R&D teams.

Background

U.S. technological dominance in ME materials, processes, devices, and architectural designs can only be sustained through the development of a robust domestic innovation ecosystem that fosters the rapid development and transition of novel concepts into commercially viable manufacturing processes. The U.S. innovation ecosystem has long been the driver of our nation's technology leadership throughout the world. U.S. R&D kick-started the enormous semiconductor industry and continues to lead the world in developing the next generation of disruptive technologies including: new materials, devices, circuits, architectures, and design tools.

In recent years, the efficient domestic adoption of U.S. chip innovation has been threatened as emerging hardware technologies have become increasingly reliant on offshore sources for State of the Art (SOTA) manufacturing, prototyping, and investment. There are several significant hurdles that hardware startups face, including limited or expensive access to necessary facilities and design infrastructure, high costs of design intellectual property, limited expertise with hardware engineering, and high costs of prototyping. As a result, the number of U.S. hardware startups has dropped significantly and foreign investment in U.S.-based technology startups has enabled offshore fabrication and maturation of emerging technologies.

Exhibit R-2, RDT&E Budget Item Justification: PB 2024 Office of the Secret	ary Of Defense	Date: March 2023
Appropriation/Budget Activity 0403D: Creating Helpful Incentives To Produce Semi-Conductors (CHIPS) for	R-1 Program Element (Number/Name) PE 0603669D8Z / Microelectronics Common	S
America I BA 3: Advanced Technology Development (ATD)		
To address these needs, OUSD(R&E) is standing up the ME Commons as a p to foster a pipeline of innovative ideas and talent residing in university labs and specialized lab equipment, technical expertise, and connections to existing or facilities will help mature promising technologies and demonstrate the manufact and commercial sectors.	d small business R&D teams. The partnership upgraded low-volume prototyping facilities. Th	will provide resources for and access to nese low-volume fabrication and packaging
The ME Commons will focus on critical, on-shore prototyping to transition inno are:	vation from universities, start-ups, and small c	ompanies to manufacturing. Key features
 Creates and connects "Lab-to-Fab" testing/prototyping hubs to form a networ Provides broad access to these prototyping hubs, potentially by augmenting or FFRDCs. 		-
• Facilitates ME education and training of students at local colleges and univer contribute more broadly to the growth of a domestic semiconductor workforce.		er local semiconductor economies and
This program element focuses on the technology development activities of the development, and significant prototyping activity. In addition, it provides for the Company (MCMC), the overall management of the ME Commons, needed ME wafer brokerage that will support the entire Commons network.	e establishment, staffing, and operation of the	Microelectronics Commons Management

B. Program Change Summary (\$ in Millions)	<u>FY 2022</u>	<u>FY 2023</u>	FY 2024 Base	FY 2024 OCO	FY 2024 Total
Previous President's Budget	0.000	0.000	0.000	-	0.000
Current President's Budget	0.000	269.256	269.256	-	269.256
Total Adjustments	0.000	269.256	269.256	-	269.256
Congressional General Reductions	-	-			
 Congressional Directed Reductions 	-	-			
 Congressional Rescissions 	-	-			
Congressional Adds	-	-			
 Congressional Directed Transfers 	-	-			
Reprogrammings	-	-			
SBIR/STTR Transfer	-	-			
CHIPS Act of 2022 Appropriation	-	269.256	269.256	-	269.256

Change Summary Explanation

This PE is funded by the CHIPS for America Defense Fund special appropriation established by the CHIPS Act of 2022, not the annual Defense appropriation. The CHIPS Act appropriates funds for this effort from FY 2023 through 2027.

Exhibit R-2A, RDT&E Project Ju	stification	: PB 2024 C	Office of the	Secretary (Of Defense					Date: Marc	ch 2023	
Appropriation/Budget Activity 0403D / 3					-	am Elemen 69D8Z / Mici	•		Project (N 829 / Micro – Prototypi	pelectronics	ne) Research N	Naturation
COST (\$ in Millions)	Prior Years	FY 2022	FY 2023	FY 2024 Base	FY 2024 OCO	FY 2024 Total	FY 2025	FY 2026	FY 2027	FY 2028	Cost To Complete	Total Cost
829: Microelectronics Research Maturation – Prototyping	-	0.000	267.923	267.923	-	267.923	255.775	242.953	254.426	0.000	Continuing	Continuing
Quantity of RDT&E Articles	-	-	-	-	-	-	-	-	-	-		

A. Mission Description and Budget Item Justification

This project focuses on the advanced technology development activities of the ME Commons including prototyping of devices or components using new ME materials, processes, device designs, and architectural designs.

It will also enable the establishment and operation of an independent Microelectronics Commons Management Company (MCMC), which will provide efficient coordination and administration of regional innovation hubs. The MCMC will be tasked with selecting and operating the ME Commons network, in alignment with the OUSD(R&E) feedback and vision to ensure DoD access to and benefit from resulting technologies. The MCMC will conduct the competition to select ME Commons Hubs (see below) from existing entities and operate them in collaboration with local management. The MCMC will provide oversight responsibility to facilitate the administrative, legal, and business functions of the Hubs, and will report directly to the government-designated program manager. The MCMC will also coordinate and manage regional Hub access to shared resources such as licenses for electronic design automation (EDA) tools and cutting-edge fabrication facilities. This eliminates the need for each regional Hub to establish relationships with foundries and EDA tool vendors and avoids duplication of efforts across the network.

The project also supports the establishment of the ME Commons Hubs, which will be new strategic partnerships with existing academic facilities and research labs. The Hubs will be augmented to enhance intrinsic specializations in emerging areas of ME. This project supports the establishment of strategic relationships with Core facilities, which are existing state-of-the-art ME productions facilities (foundries or fabs). The Cores will be connected to the regional Hubs and open to all ME Commons users.

B. Accomplishments/Planned Programs (\$ in Millions)	FY 2022	FY 2023	FY 2024
Title: Microelectronics Research Maturation – Prototyping	0.000	267.923	267.923
Description: This effort focuses on the development and prototyping of promising new ME materials, processes, devices, and architectural designs with potential DoD applications, and development of these technologies. It will also support the selection and stand-up of the Microelectronics Commons Management Company (MCMC). Finally, it will support initial selection and operation of regional ME Commons Hubs and network-wide ME Commons Cores, in conjunction with activities funded by PEs 0602669D8Z and 0604669D8Z.			
FY 2023 Plans: • Select and stand up Microelectronics Commons Management Company (MCMC) to manage and coordinate the ME Commons network			

Exhibit R-2A, RDT&E Project Justification: PB 2024 Office of the Secretary	Of Defense		Date: N	larch 2023	
Appropriation/Budget Activity 0403D / 3	R-1 Program Element (Number/Name) PE 0603669D8Z / Microelectronics Commo ns	8291	ct (Number/N Microelectron otyping	Name) nics Research	Maturation
B. Accomplishments/Planned Programs (\$ in Millions)		[FY 2022	FY 2023	FY 2024
 and activities Secure agreements for Commons design ecosystem components, including I cloud design services, etc. Establish ME Commons wafer brokerage, including logistics and legal framew Initiate wafer brokerage operations, including cost of foundry wafers and mas Select initial ME Commons Hubs and Cores through MCMC Initiate development and prototyping efforts for new ME technologies with potential for the second se	vork. sk sets	ocks,			
 FY 2024 Plans: Operate and maintain the MCMC Maintain for Commons design ecosystem components (EDA licenses, IP blocking) Continue and expand wafer brokerage operations, including cost of foundry were select remaining ME Commons Hubs to build out ME Commons network Continue and expand development and prototyping efforts for new ME technology 	vafers and mask sets	tions			
FY 2023 to FY 2024 Increase/Decrease Statement: N/A					
	Accomplishments/Planned Programs Sub	ototals	0.000	267.923	267.923
<u>C. Other Program Funding Summary (\$ in Millions)</u> N/A <u>Remarks</u> <u>D. Acquisition Strategy</u> N/A					

Exhibit R-3, RDT&E F	Project C	ost Analysis: PB 2	2024 Offic	ce of the	Secretary	Of Defer	ise					Date:	March 2	023	
Appropriation/Budget Activity 0403D / 3							ogram Ele 3669D8Z	•		Number/Name) roelectronics Research Maturation ping					
Product Developmer	nt (\$ in Mi	illions)		FY	2022	FY 2	2023		2024 Ise		2024 CO	FY 2024 Total			
Cost Category Item	Contract Method & Type	Performing Activity & Location	Prior Years	Cost	Award Date	Cost	Award Date	Cost	Award Date	Cost	Award Date	Cost	Cost To Complete	Total Cost	Target Value of Contract
Microelectronics Research Maturation – Prototyping	C/Various	Air Force, Army, Navy: Various : Various	-	-		267.923	Mar 2023	267.923	Mar 2023	-		267.923	Continuing	Continuing	-
		Subtotal	-	-		267.923		267.923		-		267.923	Continuing	Continuing	N/A
			Prior Years	FY	2022	FY	2023		2024 Ise		2024 CO	FY 2024 Total	Cost To Complete	Total Cost	Target Value of Contract
	_	Project Cost Totals	-	-		267.923		267.923		-		267.923	Continuing	Continuing	N/A

Remarks

Exhibit R-4, RDT&E Schedule Profile: PB 2024 (Office	of th	ne S	ecre	etar	y Of	Defe	ense	;													Dat	e: M	arch	202	23		
Appropriation/Budget Activity 0403D / 3										-				•	mbe ctron				829	ο ΓΝ	•					arch	Ma	turation
		FY 2	022			FY 2	2023	3		FY	202	4		FY	202	5		FY	2026	5		FY	2027	,		FY 2	028	
	1	2	3	4	1	2	3	4	1	2	3	4	1	1 2	3	4	1	2	3	4	1	2	3	4	1	2	3	4
Microelectronics Research Maturation – Prototyping																											,	
Microelectronics Commons Management Company (MCMC)																												
Commons design ecosystem (EDA licenses, IP blocks, cloud design services, etc.)																												
Commons wafer brokerage																												
Commons Hubs and Cores																												
Development and prototyping efforts																												

Appropriation/Budget Activity R-1 Program Element (Number/Name) Project (Number/Name) 0403D / 3 PE 0603669D8Z / Microelectronics Commo 829 / Microelectronics Research Maturation	Exhibit R-4A, RDT&E Schedule Details: PB 2024 Office of the Secretary Of I	Date: March 2023		
ns – Prototyping				pelectronics Research Maturation

Schedule Details

	St	art	End		
Events by Sub Project	Quarter	Year	Quarter	Year	
Microelectronics Research Maturation – Prototyping					
Microelectronics Commons Management Company (MCMC)	1	2023	4	2028	
Commons design ecosystem (EDA licenses, IP blocks, cloud design services, etc.)	1	2023	4	2028	
Commons wafer brokerage	1	2023	4	2028	
Commons Hubs and Cores	1	2023	4	2028	
Development and prototyping efforts	1	2023	4	2028	

Exhibit R-2A, RDT&E Project Ju Appropriation/Budget Activity 0403D / 3											Date: March 2023 Iumber/Name) kforce Development – Prototypin				
COST (\$ in Millions)	Prior Years	FY 2022	FY 2023	FY 2024 Base	FY 2024 OCO	FY 2024 Total	FY 2025	FY 2026	FY 2027	FY 2028	Cost To Complete	Total Cost			
830: Workforce Development – Prototyping	-	0.000	1.333	1.333	-	1.333	9.333	17.778	10.22	2 0.000	Continuing	Continuin			
Quantity of RDT&E Articles	-	-	-	-	-	-	-	-	-	-					
 local semiconductor economies a B. Accomplishments/Planned P <i>Title:</i> Workforce Development – F <i>Description:</i> This effort will direct technology development and protet Hub facilities and internships at C potential for impact beyond the err <i>FY 2023 Plans:</i> Develop and establish internship Develop training for existing non <i>FY 2024 Plans:</i> Continue and expand internships 	Prototyping tly support to otyping action ore facilities natities partice os and post os for Core a-student M	in Millions workforce de ivities. Activ s. Additiona ipating direct -doc training facilities E Commons	evelopment vities include ally, it will de ctly in the M g programs s workforce	activities the establishrevelop train Exclop train E Commor	nrough the I ment of PhE ing for the e ns Core and ilities	ME Commo) internships existing ME	ns network s and post-c Commons v	through loc training	at	Y 2022	FY 2023 1.333	FY 2024 1.33			
 Continue and expand internships Continue and expand training for FY 2023 to FY 2024 Increase/Detection 	s for Core f r existing n	acilities on-student I													
N/A	crease sia	itement.													
					Accomplis	shments/Pl	anned Prog	grams Sub	totals	0.000	1.333	1.33			
<u>C. Other Program Funding Sum</u> N/A	mary (\$ in	<u>Millions)</u>													

Exhibit R-2A, RDT&E Project Justification: PB 2024 Office of	the Secretary Of Defense	Date: March 2023
Appropriation/Budget Activity 0403D / 3	R-1 Program Element (Number/Name) PE 0603669D8Z / Microelectronics Commo ns	Project (Number/Name) 830 / Workforce Development – Prototyping
C. Other Program Funding Summary (\$ in Millions)		
Remarks		
D. Acquisition Strategy		
N/A		

Exhibit R-4, RDT&E Schedule Profile: PB 2024	Office	e of t	he Se	ecre	etary	y Of	Def	ense	Э													Jate	e: Ma	arch	202	23		
Appropriation/Budget Activity 0403D / 3										-	am E 69D82			-					-		t (Nu /orkfo					ent –	Prot	otyping
		FY 2	2022			FY 2	2023	3		FY	(202	4		FY	2025			FY	2026		F	=Y :	2027	,		FY 2	028	
	1	2	3	4	1	2	3	4	1	2	2 3	4	1	2	3	4	1	2	3	4	1	2	3	4	1	2	3	4
Workforce Development – Prototyping																												
Internships and post-doc training programs for Hub facilities																												
Internships for Core facilities																												
Training for existing non-student ME Commons workforce																												

xhibit R-4A, RDT&E Schedule Details: PB 2024 Office of the Secreta	ry Of Defense			Date: Marc	h 2023
ppropriation/Budget Activity 403D / 3	R-1 Program Elem PE 0603669D8Z / M ns			Project (Number/Nam 830 / Workforce Develo	,
	Schedule Details				
		Sta	art	Er	nd
Events by Sub Project		Quarter	Year	Quarter	Year
Workforce Development – Prototyping					
Internships and post-doc training programs for Hub facilities		1	2023	4	2028
Internships for Core facilities		1	2023	4	2028
Training for existing non-student ME Commons workforce		1	2023	4	2028

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Exhibit R-2, RDT&E Budget Iten	n Justificat	i on: PB 202	24 Office of	the Secreta	ary Of Defer	nse			Date: March 2023						
Appropriation/Budget Activity 0403D: Creating Helpful Incentive America I BA 4: Advanced Compo			•	- / -	-	am Elemen 9D8Z / Mic.	•	5							
COST (\$ in Millions)	Prior Years	FY 2022	FY 2023	FY 2024 Base	FY 2024 OCO	FY 2024 Total	FY 2025	FY 2026	FY 2027	FY 2028	Cost To Complete	Total Cost			
Total Program Element	-	0.000	65.682	65.682	-	65.682	62.704	59.560	62.373	0.000	0.000 Continuing Con				
832: Microelectronics Research Maturation – Advanced Prototyping	-	0.000	65.682	65.682	-	65.682	62.704	0.000	Continuing	Continuing					

<u>Note</u>

Funding begins in FY 2023 as provided in the Creating Helpful Incentives to Produce Semiconductors (CHIPS) Act of 2022 appropriation, not in the FY 2023 annual Defense appropriation.

A. Mission Description and Budget Item Justification

This program supports the Department's initiatives to Build Sustainable and Long-Term Advantage, Defend the Homeland, and Deter Aggression.

The Office of the Under Secretary of Defense for Research and Engineering (OUSD(R&E)) is standing up the Microelectronics (ME) Commons activity pursuant to the Fiscal Year (FY) 2021 National Defense Authorization Act (NDAA) (Pub. L. 116-283), including the CHIPS (Creating Helpful Incentives to Produce Semiconductors) for America Act, and funded through the CHIPS for America Defense Fund established by the CHIPS Act of 2022. The FY 2021 NDAA legislation significantly emphasizes solutions that promote the domestic on-shoring of capabilities to address economic and technology security concerns. Under FY 2021 NDAA Sec. 9903(b), DoD is directed to establish a National Network for Microelectronics Research and Development (NNMRD) to enable the laboratory-to-fabrication transition of microelectronics innovations in the United States and to expand the global leadership in microelectronics of the United States. Specifically, DoD is addressing a component of the NNMRD, the ME Commons, through a public-private partnership consisting of regional innovation hubs distributed across the U.S. to foster a pipeline of innovative ideas and talent residing in university labs and small business R&D teams.

Background

U.S. technological dominance in ME materials, processes, devices, and architectural designs can only be sustained through the development of a robust domestic innovation ecosystem that fosters the rapid development and transition of novel concepts into commercially viable manufacturing processes. The U.S. innovation ecosystem has long been the driver of our nation's technology leadership throughout the world. U.S. R&D kick-started the enormous semiconductor industry and continues to lead the world in developing the next generation of disruptive technologies including: new materials, devices, circuits, architectures, and design tools.

In recent years, the efficient domestic adoption of U.S. chip innovation has been threatened as emerging hardware technologies have become increasingly reliant on offshore sources for State of the Art (SOTA) manufacturing, prototyping, and investment. There are several significant hurdles that hardware startups face, including limited or expensive access to necessary facilities and design infrastructure, high costs of design intellectual property, limited expertise with hardware engineering, and high costs of prototyping. As a result, the number of U.S. hardware startups has dropped significantly and foreign investment in U.S.-based technology startups has enabled offshore fabrication and maturation of emerging technologies.

xhibit R-2, RDT&E Budget Item Justification: PB 2024 (Office of the Secretar	y Of Defense		Date:	March 2023
ppropriation/Budget Activity 403D: Creating Helpful Incentives To Produce Semi-Condu merica I BA 4: Advanced Component Development & Prote	ctors (CHIPS) for	-	ment (Number/Name) I Microelectronics Com		
To address these needs, OUSD(R&E) is standing up the M to foster a pipeline of innovative ideas and talent residing in specialized lab equipment, technical expertise, and connect acilities will help mature promising technologies and demor and commercial sectors.	university labs and s ions to existing or up	small business R ograded low-volu	&D teams. The partner me prototyping facilities	ship will provide resou . These low-volume fa	rces for and access to brication and packagin
The ME Commons will focus on critical, on-shore prototypin are:	g to transition innova	ation from univer	sities, start-ups, and sm	all companies to manu	facturing. Key feature
Creates and connects "Lab-to-Fab" testing/prototyping hul Provides broad access to these prototyping hubs, potentia or FFRDCs.					emiconductor compani
Facilitates ME education and training of students at local of	olleges and universi	ties, and provide	a potential pipeline to b	olster local semicondu	ctor economies and
contribute more broadly to the growth of a domestic semico		· ·			
	nductor workforce. development and ad at and development of (fabs). The ME Con	dvanced prototyp of a path for succ nmons will estab	essful Lab-to-Fab techr ish early and sustained	ology transition. This engagement with indu	will require significant stry and academic
ontribute more broadly to the growth of a domestic semico his program element focuses on the advanced component lub facilities, prototype development, and the establishmer ndustry buy-in from state-of-the-art ME fabrication facilities takeholders to build consensus on technology roadmaps to lans.	nductor workforce. development and ad at and development of (fabs). The ME Con	dvanced prototyp of a path for succ nmons will estab	essful Lab-to-Fab techr ish early and sustained	ology transition. This engagement with indu	will require significant stry and academic
ontribute more broadly to the growth of a domestic semicons is program element focuses on the advanced component ub facilities, prototype development, and the establishmer dustry buy-in from state-of-the-art ME fabrication facilities akeholders to build consensus on technology roadmaps to ans.	nductor workforce. development and ad at and development of (fabs). The ME Con o guide maturation an	dvanced prototyp of a path for succ nmons will estab nd delivery of inn	essful Lab-to-Fab techr ish early and sustained ovation into a given cor	nology transition. This engagement with indu nmercial fabricator's pi	will require significant istry and academic lot line and production
ntribute more broadly to the growth of a domestic semicons his program element focuses on the advanced component ub facilities, prototype development, and the establishmer dustry buy-in from state-of-the-art ME fabrication facilities akeholders to build consensus on technology roadmaps to ans.	nductor workforce. development and ad and development of (fabs). The ME Con o guide maturation an <u>FY 2022</u>	dvanced prototyp of a path for succ nmons will estab nd delivery of inn <u>FY 2023</u>	essful Lab-to-Fab techr ish early and sustained ovation into a given cor <u>FY 2024 Base</u>	nology transition. This engagement with indu nmercial fabricator's pi	will require significant stry and academic lot line and production <u>FY 2024 Total</u>
ntribute more broadly to the growth of a domestic semico is program element focuses on the advanced component ib facilities, prototype development, and the establishmer lustry buy-in from state-of-the-art ME fabrication facilities akeholders to build consensus on technology roadmaps to ans. Program Change Summary (\$ in Millions) Previous President's Budget	nductor workforce. development and ad and development of (fabs). The ME Con o guide maturation an <u>FY 2022</u> 0.000	dvanced prototyp of a path for succ nmons will estab nd delivery of inn <u>FY 2023</u> 0.000	essful Lab-to-Fab techr ish early and sustained ovation into a given cor <u>FY 2024 Base</u> 0.000	nology transition. This engagement with indu nmercial fabricator's pi	will require significant stry and academic lot line and production <u>FY 2024 Total</u> 0.000
ntribute more broadly to the growth of a domestic semico is program element focuses on the advanced component ib facilities, prototype development, and the establishmer dustry buy-in from state-of-the-art ME fabrication facilities akeholders to build consensus on technology roadmaps to ans. Program Change Summary (\$ in Millions) Previous President's Budget Current President's Budget	nductor workforce. development and ad at and development of (fabs). The ME Con o guide maturation an <u>FY 2022</u> 0.000 0.000	dvanced prototyp of a path for succ nmons will estab nd delivery of inn <u>FY 2023</u> 0.000 65.682	essful Lab-to-Fab techr ish early and sustained ovation into a given cor <u>FY 2024 Base</u> 0.000 65.682	nology transition. This engagement with indu nmercial fabricator's pi	will require significant Istry and academic Iot line and production <u>FY 2024 Total</u> 0.000 65.682
ntribute more broadly to the growth of a domestic semico is program element focuses on the advanced component ib facilities, prototype development, and the establishmer lustry buy-in from state-of-the-art ME fabrication facilities akeholders to build consensus on technology roadmaps to ans. Program Change Summary (\$ in Millions) Previous President's Budget Current President's Budget Total Adjustments	nductor workforce. development and ad at and development of (fabs). The ME Con o guide maturation an <u>FY 2022</u> 0.000 0.000	dvanced prototyp of a path for succ nmons will estab nd delivery of inn <u>FY 2023</u> 0.000 65.682	essful Lab-to-Fab techr ish early and sustained ovation into a given cor <u>FY 2024 Base</u> 0.000 65.682	nology transition. This engagement with indu nmercial fabricator's pi	will require significant Istry and academic Iot line and production <u>FY 2024 Total</u> 0.000 65.682
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Intribute more broadly to the growth of a domestic semicol and program element focuses on the advanced component ab facilities, prototype development, and the establishmer dustry buy-in from state-of-the-art ME fabrication facilities akeholders to build consensus on technology roadmaps to ans. Program Change Summary (\$ in Millions) Previous President's Budget Current President's Budget Total Adjustments • Congressional General Reductions • Congressional Directed Reductions • Congressional Rescissions • Congressional Adds	nductor workforce. development and ad at and development of (fabs). The ME Con o guide maturation an <u>FY 2022</u> 0.000 0.000	dvanced prototyp of a path for succ nmons will estab nd delivery of inn <u>FY 2023</u> 0.000 65.682	essful Lab-to-Fab techr ish early and sustained ovation into a given cor <u>FY 2024 Base</u> 0.000 65.682	nology transition. This engagement with indu nmercial fabricator's pi	will require significant Istry and academic Iot line and production <u>FY 2024 Total</u> 0.000 65.682
ntribute more broadly to the growth of a domestic semicol is program element focuses on the advanced component ib facilities, prototype development, and the establishmer dustry buy-in from state-of-the-art ME fabrication facilities akeholders to build consensus on technology roadmaps to ans. Program Change Summary (\$ in Millions) Previous President's Budget Current President's Budget Total Adjustments • Congressional General Reductions • Congressional Directed Reductions • Congressional Rescissions • Congressional Adds • Congressional Directed Transfers	nductor workforce. development and ad at and development of (fabs). The ME Con o guide maturation an <u>FY 2022</u> 0.000 0.000	dvanced prototyp of a path for succ nmons will estab nd delivery of inn <u>FY 2023</u> 0.000 65.682	essful Lab-to-Fab techr ish early and sustained ovation into a given cor <u>FY 2024 Base</u> 0.000 65.682	nology transition. This engagement with indu nmercial fabricator's pi	will require significant Istry and academic Iot line and production <u>FY 2024 Total</u> 0.000 65.682
Antribute more broadly to the growth of a domestic semicology and program element focuses on the advanced component ab facilities, prototype development, and the establishmer dustry buy-in from state-of-the-art ME fabrication facilities akeholders to build consensus on technology roadmaps to ans. Program Change Summary (\$ in Millions) Previous President's Budget Current President's Budget Total Adjustments • Congressional General Reductions • Congressional Directed Reductions • Congressional Rescissions • Congressional Adds • Congressional Directed Transfers • Reprogrammings	nductor workforce. development and ad at and development of (fabs). The ME Con o guide maturation an <u>FY 2022</u> 0.000 0.000	dvanced prototyp of a path for succ nmons will estab nd delivery of inn <u>FY 2023</u> 0.000 65.682	essful Lab-to-Fab techr ish early and sustained ovation into a given cor <u>FY 2024 Base</u> 0.000 65.682	nology transition. This engagement with indu nmercial fabricator's pi	will require significant Istry and academic Iot line and production <u>FY 2024 Total</u> 0.000 65.682
ontribute more broadly to the growth of a domestic semico his program element focuses on the advanced component lub facilities, prototype development, and the establishmer ndustry buy-in from state-of-the-art ME fabrication facilities takeholders to build consensus on technology roadmaps to lans. Program Change Summary (\$ in Millions) Previous President's Budget Current President's Budget Total Adjustments • Congressional General Reductions • Congressional Directed Reductions • Congressional Adds • Congressional Directed Transfers	nductor workforce. development and ad at and development of (fabs). The ME Con o guide maturation an <u>FY 2022</u> 0.000 0.000	dvanced prototyp of a path for succ nmons will estab nd delivery of inn <u>FY 2023</u> 0.000 65.682	essful Lab-to-Fab techr ish early and sustained ovation into a given cor <u>FY 2024 Base</u> 0.000 65.682	nology transition. This engagement with indu nmercial fabricator's pi	will require significant Istry and academic Iot line and production <u>FY 2024 Total</u> 0.000 65.682

Change Summary Explanation

This PE is funded by the CHIPS for America Defense Fund special appropriation established by the CHIPS Act of 2022, not the annual Defense appropriation. The CHIPS Act appropriates funds for this effort from FY 2023 through 2027.

Exhibit R-2A, RDT&E Project Ju	stification	: PB 2024 C	Office of the	Secretary (Of Defense					Date: Marc	ch 2023	
Appropriation/Budget Activity 0403D / 4	priation/Budget Activity R-1 Program Element (Number/Name) Project											
COST (\$ in Millions)	Prior Years	FY 2022	FY 2023	FY 2024 Base	FY 2024 OCO	FY 2024 Total	FY 2025	FY 2026	FY 2027	FY 2028	Cost To Complete	Total Cost
832: Microelectronics Research Maturation – Advanced Prototyping	-	0.000	65.682	65.682	-	65.682	62.704	59.560	62.373	0.000	Continuing	Continuing
Quantity of RDT&E Articles	-	-	-	-	-	-	-	-	-	-		
A. Mission Description and Budget Item Justification												

This project focuses on the advanced component development and advanced prototyping activities of the ME Commons. Additionally, it focuses on providing costeffective ways to capture and incentivize domestic R&D for various semiconductor technologies in a low-volume production environment and transition them for DoD and commercial market applications. Specifically, it works to transition developments from ME Commons Hubs resulting from technology identification and research funded by ME Commons PEs 0602669D8Z, and matured by activities funded by ME Commons PE 0603669D8Z.

The project also supports the establishment of the ME Commons Hubs, which will be new strategic partnerships with existing academic facilities and research labs. The Hubs will be augmented to enhance intrinsic specializations in emerging areas of ME. This project supports the establishment of strategic relationships with Core facilities, which are existing state-of-the-art ME productions facilities (foundries or fabs). The Cores will be connected to the regional Hubs and open to all ME Commons users.

B. Accomplishments/Planned Programs (\$ in Millions)	FY 2022	FY 2023	FY 2024
Title: Microelectronics Research Maturation – Advanced Prototyping	0.000	65.682	65.682
Description: This effort focuses on the advanced prototyping of promising new ME technologies and enabling the transition of these technologies to into tightly controlled high-volume fabrication processes. It will also support initial selection and operation of regional ME Commons Hubs and network-wide ME Commons Cores, in conjunction with activities funded by PEs 0603669D8Z and 0604669D8Z.			
 FY 2023 Plans: Select initial ME Commons Hubs and Cores Initiate advanced prototyping efforts for new ME technologies with potential DoD or dual-use applications Develop pathways to transition novel concepts matured in a low-volume production environment into commercially viable high-volume manufacturing processes. 			
 FY 2024 Plans: Select remaining ME Commons Hubs to build out ME Commons network Continue and expand advanced prototyping efforts for new ME technologies with potential DoD or dual-use applications 			

Exhibit R-2A, RDT&E Project Justification: PB 2024 Office of	f the Secretary Of Defense	D	ate: March 2023	
Appropriation/Budget Activity 0403D / 4	R-1 Program Element (Number/Name) PE 0604669D8Z <i>I Microelectronics Commo</i> <i>ns</i>	Project (Nun 832 / Microel – Advanced I	ectronics Researcl	h Maturation
B. Accomplishments/Planned Programs (\$ in Millions)		FY 20)22 FY 2023	FY 2024
 Maintain and expand pathways to transition novel concepts may viable high- volume manufacturing processes. 	atured in a low-volume production environment into commerc	cially		
	Accomplishments/Planned Programs Sub	ototals (0.000 65.682	65.682
<u>Remarks</u> <u>D. Acquisition Strategy</u> N/A				

Exhibit R-3, RDT&E F	Project C	ost Analysis: PB 2	2024 Offic	e of the	Secretary	Of Defen	ise					Date:	March 20	023	
Appropriation/Budge 0403D / 4	et Activity	,					o gram Ele 4669D8Z	•			832 I M	(Numbe icroelectro nced Proto	onics Res	earch Ma	ituration
Product Developmer	nt (\$ in Mi	llions)		FY	2022	FY 2	2023		2024 ase		2024 CO	FY 2024 Total			
Cost Category Item	Contract Method & Type	Performing Activity & Location	Prior Years	Cost	Award Date	Cost	Award Date	Cost	Award Date	Cost	Award Date	Cost	Cost To Complete	Total Cost	Target Value of Contract
Microelectronics Research Maturation – Advanced Prototyping	C/Various	Air Force, Army, Navy: Various : Various	-	-		65.682	Mar 2023	65.682	Mar 2024	-		65.682	Continuing	Continuing	-
		Subtotal	-	-		65.682		65.682		-		65.682	Continuing	Continuing	N/A
			Prior Years	FY	2022	FY 2	2023		2024 ase		2024 CO	FY 2024 Total	Cost To Complete	Total Cost	Target Value of Contract
	_	Project Cost Totals	-	-		65.682		65.682		-		65.682	Continuing	Continuing	N/A

Remarks

Exhibit R-4, RDT&E Schedule Profile: PB 2024	Office of	the S	Secr	etary	/ Of	Defer	nse														Date	e: Ma	arch	1 202	23		
Appropriation/Budget Activity 0403D / 4							РЕ 0		-					n ber troni				832	2 I M	licro	eleci	er/N troni ototy	ics F	Rese	arch	n Ma	nturat
		2022	1			2023			FY 2				·	2025				2026	5			2027	,		FY 2	1	;
Microelectronics Research Maturation – Advanced Prototyping	1 2	3	4	1	2	3	4	1	2	3	4	1	2	3	4	1	2	3	4	1	2	3	4	1	2	3	4
Commons Hubs and Cores																											
Advanced prototyping efforts																											
Technology transition pathways																											

xhibit R-4A, RDT&E Schedule Details: PB 2024 Office of the Secretary (Of Defense				Date: Mar	ch 2023
ppropriation/Budget Activity 403D / 4	R-1 Program E PE 0604669D8 <i>ns</i>	lement (Numbe Z I Microelectror		832 I Mid	Number/Nar roelectronics ed Prototypii	Research Maturation
S	Schedule Details					
	Γ	St	art		E	nd
Events by Sub Project		Quarter	Year		Quarter	Year
Microelectronics Research Maturation – Advanced Prototyping						
Commons Hubs and Cores		1	2023		4	2028
Advanced prototyping efforts		1	2023		4	2028
Technology transition pathways		1	2023		4	2028

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Department of Defense FY24 Spend Plan Creating Helpful Incentives to Produce Semiconductors (CHIPS) Act of 2022 (P.L. 117-167) Enacted August 9, 2022

Overview

(U) Reporting Requirement

(U) This report responds to section 8144(d) of the Consolidated Appropriations Act, 2023 (P.L. 117-328), which states:

Concurrent with the annual budget submission of the President for fiscal year 2024, the Secretary of Defense shall submit to the Committees on Appropriations of the House of Representatives and the Senate proposed allocations by account and by program, project, or activity, with detailed justifications, for amounts made available under section 102(b)(2) of the CHIPS Act of 2022 for fiscal year 2024.

(U) Report Construct

Page

(U) Tl	ne report is organized into the following subsections for clarity:	
1)	(U) Executive Summary	2
2)	(U) Spend Plan Development Process	3
3)	(U) Background	3
4)	(U) Microelectronics Commons Overview	3
5)	(U) Microelectronics Commons Structure	4
6)	(U) Microelectronics Commons Budget	7

(U) Executive Summary

(U) Division A, Section 102(b), of the CHIPS Act of 2022, appropriates in annual Fiscal Year (FY) increments of \$400 million, a total of \$2 billion for the CHIPS for America Defense Fund ("the Fund"). The Fund is established to provide for those requirements necessary to carry out section 9903(b) of the William M. (Mac) Thornberry National Defense Authorization Act (NDAA) for Fiscal Year (FY) 2021 (P.L. 116-283, codified at 15 U.S.C. 4653(b)). The \$400 million appropriated for FYs 2023 through 2027 remain available until the end of such FY for transfer into other DoD appropriations for execution, where balances merge and thus will take on the period of availability of the transferee account. FY 2023 funds are to remain available for transfer until September 30, 2023, and so on.

(U) Section 9903(b) NDAA for FY 2021 (15 U.S.C. 4653(b)) described a National Network for Microelectronics Research and Development (NNMRD) that the Secretary of Defense <u>may</u> establish, subject to availability of appropriations. Section 217 of the NDAA for FY 2022 (Public Law 117-81) amended section 9903(b) to direct the Secretary of Defense to establish the NNMRD, subject to the availability of appropriations for such purposes. Section 102(b) of the CHIPS Act of 2022 has made appropriations for the next five FYs,

(U) To accomplish this, the Under Secretary of Defense for Research & Engineering (USD(R&E)) is establishing the Microelectronics Commons (the Commons), which will focus on critical, on-shore prototyping to transition DoD innovations from universities, start-ups, and companies to manufacturing. The Commons will: create and connect "lab-to-fab" testing/prototyping hubs to form a network focused on maturing emerging microelectronics (ME) technologies, strengthening ME education and training, and developing a pipeline of talent to bolster local semiconductor economies and contribute more broadly to the growth of a domestic semiconductor workforce.

(U) The Department envisions transferring the funds into the Research, Development, Test and Evaluation, Defense-Wide (RDT&E, DW) account. In support of allocation by the President or Congress pursuant to section 102(b)(3)(B), the DoD estimates and proposes in Table 1 account and RDT&E budget activity allocations in support of allocations by the President or Congress pursuant to section 102(b)(3)(B).

Appropriation	Budget Activity	FY 2024 (\$M)
Recent Development	BA 2: Applied Research	65.062
Research, Development, Test & Evaluation,	BA 3: Advanced Technology Development (ATD)	269.256
Defense-Wide	BA 4: Advanced Component Development and	65.682
Defense-wide	Prototypes (ACD&P)	
Total		400.0

Table 1. (U) DOD Proposed Allocation for the CHIPS for America Defense Fund (P.L.117-167)

(U) Spend Plan Development Process

(U) On August 10, 2022, the Office of the Under Secretary of Defense (Comptroller) (OUSD(C)) requested that the Office of the USD(R&E) propose how it would to execute the funds appropriated into the Fund. This spend plan was developed based on existing planning for the Commons concept and its envisioned operations.

(U) Background

(U) Pursuant to the FY 2021 and 2022 NDAA direction, a USD(R&E)-led cross functional team conducted extensive planning to develop the concept and structure for the Commons. The team developed a Commons plan that aims to:

- Create "lab-to-fab" prototyping hubs to build a national R&D network focused on maturing DoD ME technologies by bridging the technological "valley of death" (TRL 3-5).
- Provide broad access to these prototyping hubs, potentially through augmented academic, industry, government and/or non-profit facilities (i.e., a local semiconductor company or a federally funded research and development center (FFRDC)).
- Facilitate ME education and training of students at local colleges and universities, and provide a potential pipeline for an engineering workforce to bolster defense microelectronics.

(U) Microelectronics Commons Overview

(U) Microelectronics Commons is a CHIPS and Science Act-funded national network for onshore, microelectronics hardware prototyping, lab-to-fab transition of semiconductor technologies and semiconductor workforce training. Commons complements other CHIPS efforts, such as the National Semiconductor Technology Center (NSTC), and will support infrastructure (physical, digital, and human) required for microelectronics prototyping across up to six DoD critical technology areas while serving National economic and security objectives. By bringing key entities together across regions to solve these microelectronics hardware prototyping challenges, collaborations and connections required for a vibrant lab-to-fab prototyping ecosystem will be established through the Commons. The resulting infrastructure and collaborations across the ecosystem, supported by CHIPS appropriations, are intended to provide a fertile foundation for future innovation and on-shore manufacturing and to serve as an asset for USG and commercial prototyping needs.

(U) There is a need for domestic prototyping capability, including infrastructure, to accelerate technology demonstration by enabling materials, processes, devices, and architectural designs to be developed and quickly ported and re-characterized as they are transitioned from university or other R&D laboratory facilities to small-volume prototyping and then scaled up for large-scale prototyping, fabrication and production. Due to the complexity and market value of today's integrated microelectronic (ME) systems and the lack of adequate on-shore prototyping in which intellectual property (IP) can be protected, there is an urgent need to establish a network of domestic prototyping facilities to demonstrate, at-scale, the system level benefits of innovations in microelectronics materials, processes, devices, and architectural designs. Demonstrating at-scale commercial viability is required to close the gap between university, small business and

other laboratory innovations and marketplace adoption. However, at-scale prototyping is highrisk, expensive and often not readily available at scale for other than large and established companies. As a result, small and mid-size companies and universities have a great difficulty bridging the gap between research ideas and translation of those ideas into microelectronics hardware prototypes. In particular, prototyping capabilities for six technology areas that are important to the Department of Defense (DoD) will be supported with seed projects in order to partially offset prototyping facility operating costs and to give these facilities experience in supporting outside users. These areas include secure edge/Internet of Things (IoT) computing, 5G/6G technology, artificial intelligence hardware, quantum technology, electronic warfare, and commercial leap ahead technologies. While each is important to the DoD, it is also likely that these areas may have substantial dual-use marketability.

(U) Microelectronics Commons Structure

(U) The proposed organizational structure for the Commons consists of an independent Consortium Manager (CM), multiple regional Innovation Hubs, and Core facilities. A non-profit CM will facilitate efficient coordination of the regional innovation Hubs as well as connections between the Hubs and Core Facilities. This approach provides the CM with the flexibility to access agreements to startups and/or innovators to help accelerate the execution of projects supported through the Hubs.

Innovation Hubs will be networks of regional capabilities that will be organized in collaboration with the CM to address DoD and commercial needs and requirements. Each Hub will concentrate on one of six application areas including: Secure Edge Computing, 5G/6G Technology, Artificial Intelligence Hardware, Quantum Computing, Electronic Warfare, and Commercial Leap Ahead Technologies. The Core Facilities will provide key capabilities that are required to demonstrate prototypes with the volume and characteristics required to ensure reduced risk for full manufacturing production.

See Figure 1 for an overview of the Microelectronics Commons concept.

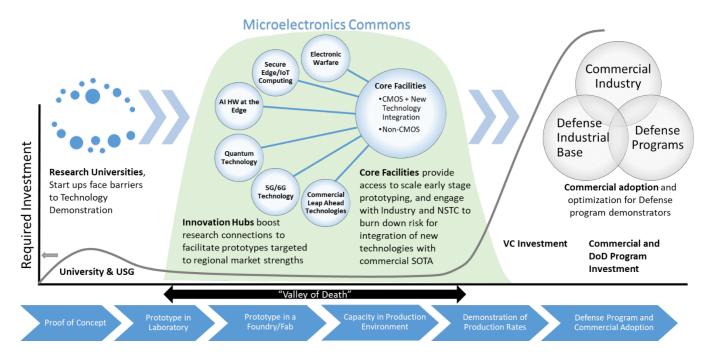


Figure 1: (U) Microelectronics Commons Concept

(U) The envisioned network consists of:

- (U) CM: An independent CM will provide efficient coordination and administration of the regional innovation hubs. The CM will facilitate the establishment of an advisory board consisting of a representative from each Hub, USG and commercial organizations. The CM will conduct the process to competitively select the hubs in collaboration with DoD oversight.
- (U) <u>Innovation Cores and Hubs</u>: This network of regional facilities will be organized to address DoD needs and requirements. Existing academic facilities may be augmented to enhance intrinsic specializations in emerging areas of ME. The Commons will include multiple (6-9) hubs that establish agreements with core facilities to deliver DoD ME innovations within the spectrum of regional markets across the U.S.
 - (U) The innovation hubs will provide innovative hub models and provide enhanced prototyping flexibility to introduce new materials and processes supporting a broader range of technology demonstrations. Ideal hub candidates would leverage and enhance existing capabilities at academic or small business facilities that include myriad instruments, material deposition chambers, lithography, test and measurement tools, etc. Hubs will maintain and operate a variety of tools to enable processing of a broad range of wafer sizes and substrate materials. This mix of prototyping capabilities will serve to support a wide range of demonstrations to include DoD unique technologies as well as integration of new devices and materials on underlying commercial wafers and ICs that enable new performance and functionality in support of DoD missions. Selection of a hub will also be based on existing expertise and the opportunities for

workforce development. Academic institutions and small businesses within a hub can both act as a source of innovation as well as a host for sponsored efforts.

- (U) The larger core facilities will provide requisite process control to support repeatable demonstration of new technology integration as needed for a specific project. Demonstrating repeatable process integrating tools that mirror commercial processes can accelerate technology transition. It is envisioned that separate core facilities may be needed support various prototyping capabilities including CMOS integration, non-CMOS technologies, and Advanced Heterogeneous Integration facilities.
- (U) <u>Transition Partners:</u> Successful lab-to-fab transition requires DoD program of record support to help select impactful technologies and to identify transition criteria for ME matured through the Commons network. Industry feedback is needed to help assess manufacturing feasibility, and transition opportunities. The advisory board will enable early and sustained engagement with industry and hub stakeholders.
- (U) <u>Use Cases</u>: Hubs will develop access models for prototyping facilities. These models will detail the pathways for external users to access Hub and Core capabilities. See Figure 2 for an overview of use cases, which include but are not limited to:
 - Academic access lab and fab infrastructure
 - Startups access lab and fab infrastructure
 - Hubs working with Cores
 - Companies accessing Universities lab infrastructure for new materials, processes, device development, etc.
 - Cores work with other Cores based on differentiated capabilities
 - Equipment Manufacturers work with Hubs and Cores
 - Defense Program and DIB access to technology demonstrators

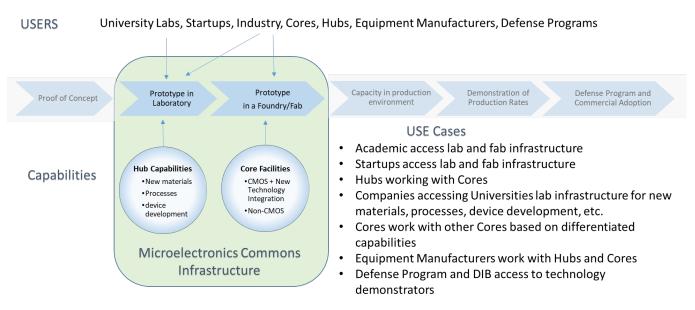


Figure 2: (U) Microelectronics Commons Use Cases

(U) Microelectronics Commons Budget

(U) A notional budget has been developed to support the plan to stand up and operate the Commons network including: CM and up to 9 hub facilities. The sample budget in Table 2 describes the funding allocations to cover the elements of the Commons across the FYDP. The sample budget in Table 3 describes the funding allocations to cover the elements of the Commons in FY24.

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		Annual Funding (\$M)				
Description	FY23	FY24	FY25	FY26	FY27	Comments
HQ Staff and Management	1	1	1	1	1	HQ support staff, coordinate across virtual network.
Acquisition Support: Contracting Fees	16	16	16	16		GOV Contracting fees (assumes projects are fully funded at award), Assumes 40 projects per year.
Consortium Management Fee	13.3	12.0	12.0	12.0	12.0	OTA consortium management fees (max 3.75%).
Acquisition Support: Tri-Service Technical Oversight	5	10	10	10		Technical execution oversight for projects across the 6 key application areas.
Tri-Service Labs	10	40.7	40.7	40.7	40.7	Tri-Service lab R&D focused on transition to the warfighter
Regional Innovation Hubs Infrastructure (CapEx and OpEx) Core/Hub facilities access Dual-use technical prototype 						CapEx [determined by needs and the growth plans of the Hubs and Cores]: new infrastructure such as tools, equipment, materials, etc. that are required for successful prototyping capability
execution Workforce development through prototype 						Usage-base access costs for use of Hub and Core capabilities
 execution; e.g., graduate student training Workforce development (\$3M FY23 ramp to 5% FY24-27); talent pipeline 						Dual-use technical prototype projects to enable the collaborations required for an enduring vibrant lab-to-fab ecosystem; e.g., for Cores to better align Hubs with commercial processes
tailored to Hub needs beyond specialized staff supported by OpEx and graduate student training supported through prototype execution.						Workforce Development In addition to specialized staff supported by OpEx and graduate student training supported through prototype execution.
Total	355 400	320 400	320 400	320 400	320 400	

Table 2. (U) Microelectronics Commons Budget (FYDP)

Description	FY24	Comments			
Administrative Functions					
HQ Staff and Management	1	HQ support staff, coordinate across virtual network.			
Acquisition Support: Contracting Fees	16	GOV Contracting fees (assumes projects are fully funded at award), Assumes 40 projects per year.			
Consortium Management Fee	12	OTA consortium management fees (max 3.75%).			
Acquisition Support: Tri-Service Technical Oversight	10	Technical execution oversight for projects across the 6 key application areas.			
Sub-total Administrative Costs	39				
Tri-Service Labs	41	Tri-Service lab R&D focused on transition to the warfighter			
Technology Area					
Quantum Technology	53.3	CapEx [determined by needs and the			
5G/6G Technology	53.3	growth plans of the Hubs and Cores]: new infrastructure such as tools, equipment,			
Artificial Intelligence Hardware	53.3				
Commercial Leap Ahead Technologies	53.3	materials, etc. that are required for successful prototyping capability			
Electromagnetic Warfare	53.3				
Secure Edge Computing/IoT	53.3	Usage-base access costs for use of Hub and			
Regional Innovation Hubs •Infrastructure (CapEx and OpEx) •Core/Hub facilities access •Dual-use technical prototype execution > Workforce development through prototype execution; e.g., graduate student training •Workforce development (\$3M FY23 ramp to 5% FY24-27); talent pipeline tailored to Hub needs beyond specialized staff supported by OpEx and graduate student training supported through prototype execution.		Core capabilities Dual-use technical prototype projects to enable the collaborations required for an enduring vibrant lab-to-fab ecosystem; e.g., for Cores to better align Hubs with commercial processes Workforce Development In addition to specialized staff supported by OpEx and graduate student training supported through prototype execution.			
Sub-total Regional Hubs Costs	320				
Total	400				

Table 3. (U) Microelectronics Commons Detailed Budget (FY24)

- (U) Administrative Functions: Headquarters staffing supports coordination and engagements across the virtual network. Government contracting supports consortium management in the execution of agreements; consortium management also supports the facilitation of engagements across the hub ecosystem. Tri-Service technical oversight supports the technical execution oversight for the hubs and the projected 30-60 projects (estimation based on 5-10 projects per technical area).
- (U) Tri-Service labs intermediary transition projects: supports Tri-Service lab activities for lab to fab or technology transfer.
- (U) Regional Innovation Hubs: establish hub model that includes 1) semiconductor workforce development to provide critical opportunities for students to develop technical expertise through technology demonstration and engagement with expertise from academia through commercial entities across the domestic innovation ecosystem and 2) identification and development of prototype facilities equipped to mature and scale up a range of new materials, devices, architectures from lab demonstrations, and startups across a broad range of technical specialties and 3) proposed prototypes to meet technical objectives of the six technical areas. Regional Hub funding will include:
 - Capital expenditures, which includes new infrastructure such as tools, equipment, materials, etc. that are required for prototyping.
 - Usage-base access costs for use of Hub and Core capabilities.
 - Prototype project execution expenditures, which includes:
 - Operational expenditures such as infrastructure maintenance and staffing.
 - Access to Core facilities expenditures.
 - Dual-use technical prototype projects execution to support and enable the collaborations required for an enduring lab-to-fab ecosystem
 - Prototype expenditures to include labor (experts, students, support staff, etc.) and materials.
 - Workforce development, in addition to specialized staff and graduate student training, to produce a talent pipeline tailored to the needs of the Hubs.